	Application No.	Applicant(s)	
* *	10/706,093	LEE ET AL.	
Notice of Allowability	Examiner	Art Unit	
. •	HOAN C. NGUYEN	2871	
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.			
1. A This communication is responsive to election filed on 10 August 2005.			
2. The allowed claim(s) is/are <u>6-14 and 17-20</u> .			
3. ☑ The drawings filed on 13 November 2003 are accepted by the Examiner.			
 4. Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some* c) None of the: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this national stage application from the International Bureau (PCT Rule 17.2(a)). * Certified copies not received: 			
Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application. THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.			
5. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.			
6. CORRECTED DRAWINGS (as "replacement sheets") must be submitted.			
(a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached			
1) ☐ hereto or 2) ☐ to Paper No./Mail Date			
(b) ☐ including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date			
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).			
7. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.			
 Attachment(s) 1. ☑ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☑ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 11/13/03 4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material 	5. Notice of Informal P 6. Interview Summary Paper No./Mail Dat 7. Examiner's Amendr 8. Examiner's Stateme 9. Other	(PTO-413), te ment/Comment	,

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EXAMINER'S AMENDMENT

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An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Ms. Valerie P. Hayes on Oct. 20, 2005.

Ms Hayes authorizes to cancel the nonelected claims 1-5 and 15-16.

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DETAILED ACTION

Allowable Subject Matter

Claims 6-14 and 17-20 are allowed.

Reasons for Allowance

Claims 6 and 17 are allowed since there is no prior art teaches a method of fabricating a color filter substrate with steps of:

- forming an overcoat layer on the color filter layer;
- forming a positive-type photoresist layer on the overcoat layer;
- forming a photoresist pattern corresponding to the black matrix using photolithographic processes of the photoresist layer; and
- <u>etching</u> the photoresist pattern and the overcoat layer <u>to form a dielectric layer</u>.

Claims 7-14 and 18-20 are allowed since they depend on the allowed claims.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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Conclusion

Takana et al. (US 6824935 B2) disclose a substrate having an overlayer formed on a colored layer.

Oke et al. (US 6816221 B2) disclose an active matrix type liquid crystal display device including overcoat film OC made of an organic material is formed on the inside surfaces of the color filter elements CF.

Kubota et al. (US 6781148 B2) disclose a light emitting device comprising an optical thin film such as a multilayer <u>dielectric film</u> may be used instead of the <u>color</u> filter.

Asuma et al. (JP 2000019527 A) disclose an active matrix type liquid crystal display device including spacer SP on overcoating layer OC made by resin resist. This process does not contain steps forming a photoresist pattern and etching the photoresist pattern and the overcoat layer as instant application claimed.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to HOAN C. NGUYEN whose telephone number is (571) 272-2296. The examiner can normally be reached on MONDAY-THURSDAY:8:00AM-4:30PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Kim H. Robert can be reached on (571) 272-2293. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

HOAN °C. NGUYEN Examiner Art Unit 2871

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